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(54) Title: AN ANTIMICROBIAL SUBSTRATE, A METHOD AND A COMPOSITION FOR PRODUCING IT

(57) Abstract: The invention relates to an antimicrobial substrate having adhered to at least a part of its surface an organosilicon quaternary ammonium salt compound, such as 3-(trimethoxysilyl)propyl-dimethyloctadecyl ammonium chloride, and a cationic, preferably hydrophilic, polymer, such as a polyethylene imine or polyhexamethylene biguanide hydrochloride. The invention also relates to a method for producing said substrate and a composition for use in the production of said substrate.